

Supporting Information

Fabrication of TiVO_4 photoelectrode for photoelectrochemical application

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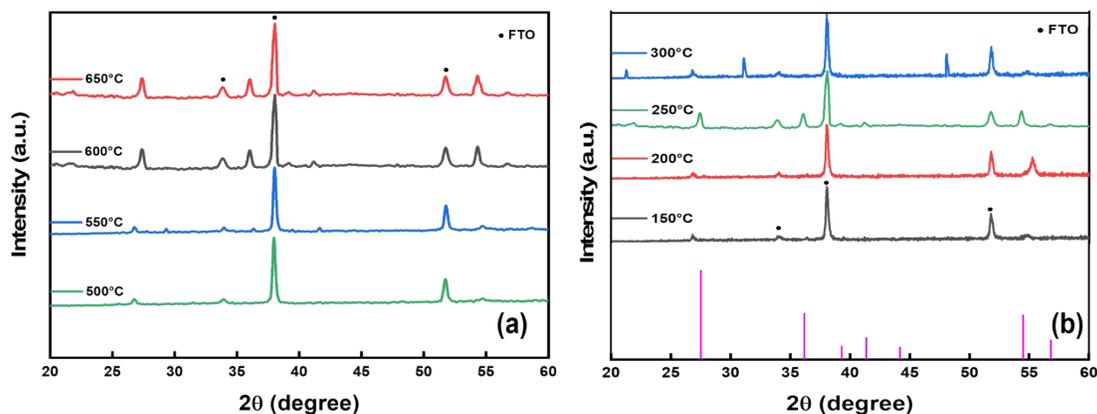


Fig. S1 XRD pattern of spray pyrolyzed TiVO_4 photoanode deposited on FTO glass at different annealing temperatures (a), and at different substrate temperatures (b).

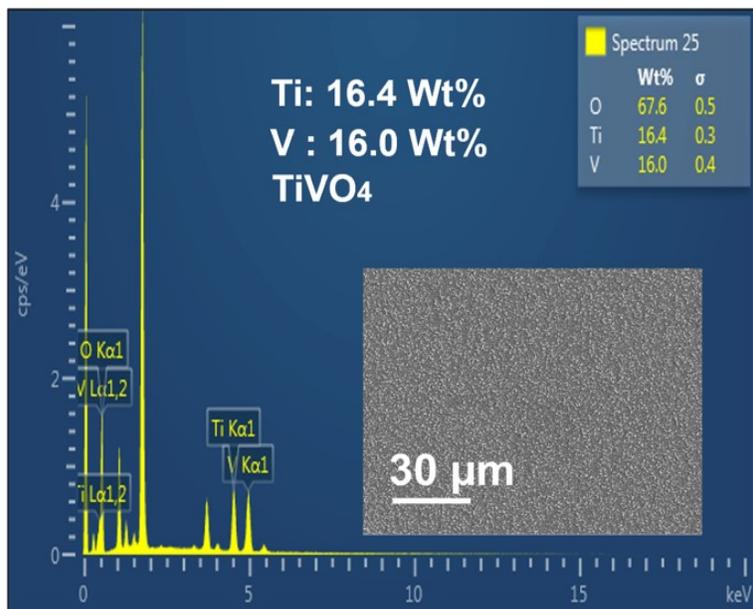


Fig. S2 EDS spectrum of pyrolyzed TiVO_4 photoanode deposited at 250°C.